L Number	Hits	Search Text	DB	Time stamp
-	5	sp-Si	USPAT;	2004/10/13 10:11
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		•	IBM_TDB	
-	2	5,397,429.pn.	USPAT;	2004/09/24 10:19
			US-PGPUB;	
\			EPO; JPO;	
			DERWENT;	
	_		IBM_TDB	
-		5397429.URPN.	USPAT	2004/09/24 10:10
-		5552328.URPN.	USPAT	2004/09/24 10:15
-		6683367.URPN.	USPAT	2004/09/24 10:17
-		6780649.URPN.	USPAT	2004/09/24 10:17
-	0	spark near silicon near volatile	USPAT;	2004/09/24 10:35
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	0001/00/01 10 00
-	8	spark adj processed near silicon	USPAT;	2004/09/24 10:20
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	6	, ,	USPAT	2004/09/24 10:22
		"4529621" "5580429" "5998048").PN.		
-		4328258.URPN.	USPAT	2004/09/24 10:24
-	1	silicon near volatile near salt	USPAT;	2004/09/24 10:36
	1		US-PGPUB;	
		,	EPO; JPO;	
			DERWENT;	
			IBM_TDB .	
-	384	silicon near salt	USPAT;	2004/09/24 10:37
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	0004/00/04 10 46
_	45	(silicon near salt) and volatile	USPAT;	2004/09/24 10:46
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		C11274C	IBM_TDB	2004/00/24 10:52
-	2	6113746.pn.	USPAT;	2004/09/24 10:53
			US-PGPUB;	
			EPO; JPO; DERWENT;	
	<u></u>			
_	6100	Uymmol in or shophord in	IBM_TDB	2004/09/24 11:28
-	5102	Hummel.in. or shepherd.in.	USPAT;	2004/03/24 11:28
			US-PGPUB;	
			EPO; JPO;	,
			DERWENT;	
l _	24	(Hummol in or chaphond in) and (acress)	IBM_TDB USPAT;	2004/09/24 11:28
-	24	'		2004/09/24 11:26
		or volatile) and silicon	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	105	430 /466	IBM_TDB	2004/00/24 12:20
-	195	438/466.ccls.	USPAT;	2004/09/24 12:28
			US-PGPUB;	
	1		EPO; JPO;	
	l		DERWENT;	
_	100	139/466 calc and cilian	IBM_TDB	2004/09/24 12:28
-	125	438/466.ccls. and silicon	USPAT; US-PGPUB;	2004/03/24 12:28
			EPO; JPO;	
			DERWENT;	
l	I		IBM_TDB	<u> </u>

3				
2	5	(438/466.ccls. and silicon) and spark\$3	USPAT;	2004/10/13 10:36
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
Ì			IBM TDB	
-	858	(438/23 or 257/93 or 438/96 or	USPĀT;	2004/09/24 12:50
		438/61).ccls.	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
İ			IBM TDB	
-	24	((438/23 or 257/93 or 438/96 or '	USPAT;	2004/09/24 12:33
		438/61).ccls.) and (aerosol or volatile or	US-PGPUB;	
1		suspension)	EPO; JPO;	
		,	DERWENT;	
		,	IBM TDB	-
_	7771	(250/252 or 250/362 or 257/13 or 257/79 or	USPAT;	2004/09/24 13:17
	'''	257/103 or 313/428 or 313/463 or 313/504	US-PGPUB;	2001,00,21
		or 313/498 or 313/346 or 438/29 or 438/69	EPO; JPO;	
		or 430/56 or 428/620).ccls.	DERWENT;	
		02 100,00 02 120,020,0020.	IBM TDB	
_	1 0	((250/252 or 250/362 or 257/13 or 257/79	USPĀT;	2004/09/24 12:55
	ľ	or 257/103 or 313/428 or 313/463 or	US-PGPUB;	2001, 03, 21 12100
		313/504 or 313/498 or 313/346 or 438/29 or	EPO; JPO;	
		438/69 or 430/56 or 428/620).ccls.) and	DERWENT;	
		(aerosol or suspension) near silicon	IBM TDB	
_	1 1	((250/252 or 250/362 or 257/13 or 257/79	USPAT;	2004/09/24 12:55
	1 -	or 257/103 or 313/428 or 313/463 or	US-PGPUB;	2004/03/24 12:33
		313/504 or 313/498 or 313/346 or 438/29 or	EPO; JPO;	
		438/69 or 430/56 or 428/620).ccls.) and	DERWENT;	
		(aerosol or suspension) near salt	IBM TDB	
_	2	1 '	USPAT;	2004/09/24 12:53
		or 257/103 or 313/428 or 313/463 or	US-PGPUB;	2004/03/24 12:33
		313/504 or 313/498 or 313/346 or 438/29 or	EPO; JPO;	
		438/69 or 430/56 or 428/620).ccls.) and	DERWENT;	
		(aerosol or suspension) near heavy	IBM TDB	
_	8		USPAT;	2004/09/24 12:55
	· °	or 257/103 or 313/428 or 313/463 or	US-PGPUB;	2004/03/24 12:33
		313/504 or 313/498 or 313/346 or 438/29 or	EPO; JPO;	
		438/69 or 430/56 or 428/620).ccls.) and	DERWENT;	
L	1	(aerosol or suspension) near liquid	IBM TDB	

÷	50	("6113746"	USPAT.	2004/09/24 13:17
•		"6361766" "6294186"		
ĺ		"6294186" "4427914"		
		"4415828"		į į
		"6251981"		
		"6391690"		
		"6428884"		
ļ		"6475598"		
		"6387357"		
		"6403069"		
		"6395889"		
		"6465495"		1
		"6407487"		
		"4547279"		
		"5342767"		
		"6399050"		***
		"5317236"		
		"5438241" "5654811"		
		"5661371"		
		"5723348"		
		"6151827"		
		"6303268"	i	
		"6465633".		
		"6475753"		•
		"5558575"		
		"6331564"		
<u> </u>		"6652667"		
		"4532896"		
		"6376674"		
		"6387355"		
		"6391289"		
		"4507410"		
		"5542194"		
		"6403708" "6455617"	· .	
		"4916393"		
		"6310262"		
		"6403346"		
		"6437142"		
1		"6440967"		
		"5210457"		
		"4967718"		
		"5811915"		
1		"6188166"		
		"6270898"		
		"6794803"		
		"4299622"		
		"4972811").pn.		
_	0	(313/141 or 424/65 or 315/169.3 or 424/59	USPAT;	2004/09/24 14:48
	, ,	or 424/401 or 424/400 or 257/E21.703 or	US-PGPUB;	
		257/E27.111 or 257/E29.273 or 257/E29.275	EPO; JPO;	
		or 257/E29.295 or 424/68 or 438/29 or	DERWENT;	
]		313/118 or 313/143 or 424/60 or 424/66 or	IBM TDB	
		428/336 or 428/694BS or 435/131 or 435/148	_	
1		or 435/252.3 or 435/320.1 or 445/1 or		
		445/7 or 536/23.5).ccls. and (spark near9		
1		process\$3 near9 silicon)		
-	6654		USPAT;	2004/10/12 11:12
		424/59).ccls.	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	21	//212/141 07 424/65 07 215/160 2 07	IBM_TDB	2004/10/12 12:11
⁻	21	((313/141 or 424/65 or 315/169.3 or 424/59).ccls.) and plasma near9 spark\$3	USPAT; US-PGPUB;	2004/10/12 12:11
		121/00/.ccts./ and prasma mears sparkss	EPO; JPO;	
			DERWENT;	
		•	IBM TDB	
-	1	6512562.pn.	USPAT	2004/10/19 10:21
		·		·

-	1115	349/122.ccls.	USPAT;	2004/10/12 11:29
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	1		IBM_TDB	
-] 1	349/122.ccls. and plasma near9 spark\$3	USPAT;	2004/10/12 11:18
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-		"20030151707"	US-PGPUB	2004/10/12 11:21
-	14	349/122.ccls. and (plasma near9 (Si or	USPAT;	2004/10/12 11:22
		silicon) and (acetone or volatile or	US-PGPUB;	
		particle))	EPO; JPO;	:
			DERWENT;	
			IBM_TDB	
-	33119	349/\$6.ccls.	USPAT;	2004/10/12 11:29
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
-	2	349/\$6.ccls. and spark near9 plasma	USPĀT;	2004/10/12 11:30
			US-PGPUB;	
			EPO; JPO;	,
	l		DERWENT;	
			IBM TDB	
_	2	("6468602" "6316062").pn.	USPĀT	2004/10/12 11:32
_		"20020064606"	US-PGPUB	2004/10/19 10:19
-	7409	427/\$6.ccls.	US-PGPUB	2004/10/12 11:41
-	7	427/\$6.ccls. and spark\$3 near9 plasma	US-PGPUB	2004/10/12 11:41
_	131470		USPAT;	2004/10/12 11:41
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
_	34	427/\$6.ccls. and spark\$3 near9 plasma	USPĀT;	2004/10/12 11:59
	1	12.7, 40.00201 una opazinto monto pranima	EPO; JPO;	
	•		DERWENT;	
			IBM TDB	
_	91	sinter\$3 near9 (si or silicon) and	USPĀT;	2004/10/12 12:04
1.00		particle near9 liquid and (spark or	EPO; JPO;	
1		plasma)	DERWENT;	
1		p = u o mu ,	IBM TDB	
_	1965	501/\$6 and 428/\$6 and silicon and	USPAT;	2004/10/12 12:05
	1300	(sinter\$3 or plasma)	EPO; JPO;	2001, 20, 22 22:00
		(Oliforta of plasma)	DERWENT;	
			IBM TDB	
I -	41	(501/\$6 and 428/\$6 and silicon and	USPĀT;	2004/10/12 12:07
		(sinter\$3 or plasma)) and spark not plug	EPO; JPO;	
1		(1211111111111111111111111111111111111	DERWENT;	
			IBM TDB	
_	10	((501/\$6 and 428/\$6 and silicon and	USPAT;	2004/10/12 12:07
1	1	(sinter\$3 or plasma)) and spark not plug)	EPO; JPO;	
	1	and spark near5 plasma or spark\$plasma	DERWENT;	
1		and spark nears prasma or sparkyprasma	IBM TDB	
- ,	21	((313/141 or 424/65 or 315/169.3 or	USPAT;	2004/10/12 12:12
	"	424/59).ccls.) and (plasma near9 spark\$3	US-PGPUB;	
		or spark\$plasma)	EPO; JPO;	
1		or oparational	DERWENT;	
1	1		IBM TDB	
_	l 0	(((313/141 or 424/65 or 315/169.3 or	USPAT;	2004/10/12 12:12
	1	424/59).ccls.) and (plasma near9 spark\$3	US-PGPUB;	
	1	or spark\$plasma)) not (((313/141 or 424/65	EPO; JPO;	
	1	or 315/169.3 or 424/59).ccls.) and plasma	DERWENT;	
	1	near9 spark\$3)	IBM TDB	
_	7		USPAT;	2004/10/12 12:12
	Ι ΄	spark\$plasma)	US-PGPUB;	2001,10,12 12.12
1	1	ορατλφτασιια/	EPO; JPO;	
	1		DERWENT;	
	1		IBM TDB	1
1	I	I		i –

-	34	427/\$6.ccls. and (plasma near9 spark\$3 or	USPAT;	2004/10/12 12:30
		spark\$plasma)	US-PGPUB;	
			EPO; JPO; DERWENT;	-
			IBM TDB	
l <u> </u>	34	(427/\$6.ccls. and (plasma near9 spark\$3 or	USPAT;	2004/10/12 12:13
	34	spark\$plasma)) not (427/\$6.ccls. and	US-PGPUB;	2004/10/12 12:13
		(plasma near9 spark\$3 or spark\$plasma))	EPO; JPO;	`
		(placema noals opalities of spaintplacema),	DERWENT;	
			IBM TDB	
_	0	spark\$plasma near9 (si or silicon)	USPAT;	2004/10/12 12:30
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
- .	4	spark adj plasma near9 (si or silicon)	USPAT;	2004/10/12 12:33
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
l _	0	spark\$plasma\$silicon	IBM_TDB USPAT;	2004/10/12 12:35
_	1	Sparkypiasmaysificon	US-PGPUB;	2004/10/12 12.33
	ļ		EPO; JPO;	
			DERWENT;	'
1	İ		IBM TDB	
-	7	spark\$process\$3 near5 silicon	USPAT;	2004/10/12 12:47
	1	·	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		•	IBM_TDB	
-	1096	313/141.ccls.	USPAT;	2004/10/12 12:48
	}		US-PGPUB;	
			EPO; JPO;	
İ			DERWENT; IBM TDB	
_	99	313/141.ccls. and (si or silicon)	USPAT;	2004/10/12 12:48
		313/141.ccis. and (SI OI SILICON)	US-PGPUB;	2004/10/12 12:40
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	96	, , , , , , , , , , , , , , , , , , , ,	USPAT;	2004/10/12 12:49
		spark\$3	US-PGPUB;	
ľ			EPO; JPO;	
			DERWENT;	
I _	2	((313/141.ccls. and (si or silicon)) and	IBM_TDB USPAT;	2004/10/12 12:49
-	4	((313/141.ccis. and (S1 or S111con)) and spark\$3) not plug	US-PGPUB;	2004/10/12 12:49
		Sparkys, not pray	EPO; JPO;	
			DERWENT;	
	1		IBM TDB	
-	9457	156/643	USPĀT;	2004/10/12 14:10
	1		US-PGPUB;	
	1		EPO; JPO;	
			DERWENT;	
		156/649	IBM_TDB	0004/10/10 1: 1:
-	23	156/643 and 148/33.4	USPAT;	2004/10/12 14:19
			US-PGPUB; EPO; JPO;	
	1		DERWENT;	
	1		IBM TDB	
_	160	photo\$lumines\$6 near6 (si or silicon) and	USPAT;	2004/10/12 14:20
	1	(spark or plasma)	US-PGPUB;	
	1		EPO; JPO;	
	1		DERWENT;	
1			IBM_TDB	
-	0	(photo\$lumines\$6 near6 (si or silicon) and	USPĀT;	2004/10/12 14:21
1		(spark or plasma)) and spark near5 plasma	US-PGPUB;	
	1		EPO; JPO;	
	1		DERWENT;	
L	l	<u> </u>	IBM_TDB	

-	8	(photo\$lumines\$6 near6 (si or silicon) and	USPAT;	2004/10/12 14:21
		(spark or plasma)) and spark near5 voltage	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	0004/10/10 14 30
-	2		USPAT	2004/10/12 14:39
-	5714	impurities near4 particles	USPAT;	2004/10/12 17:30
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	148	impurities near4 particles near9 silicon	<pre>IBM_TDB USPAT;</pre>	2004/10/12 17:30
-	140	Impurities heary particles hears siricon	US-PGPUB;	2004/10/12 17:30
			EPO; JPO;	
		•	DERWENT;	
			IBM TDB	
_ ,	2	(impurities near4 particles near9 silicon)	USPAT;	2004/10/12 17:32
		and spark	US-PGPUB;	
			EPO; JPO;	
, ,			DERWENT;	
] '			IBM TDB	
-	1	4,379,777.pn.	USPĀT	2004/10/12 17:42
-	409	423/348	USPAT	2004/10/12 17:42
-		423/348 and particle	USPAT	2004/10/12 17:42
_	72	423/348 and particle.clm.	USPAT	2004/10/12 17:43
	1	6113746.pn.	USPAT	2004/10/12 19:26
-	3112	315/169.3	USPAT;	2004/10/13 10:12
			US-PGPUB;	
			EPO; JPO;	
•			DERWENT;	
			IBM_TDB	
-	2		USPAT;	2004/10/13 10:13
		spark\$process\$3 or spark\$3 near9 plasma)	US-PGPUB;	
•			EPO; JPO;	
ľ			DERWENT; IBM TDB	
_	0	438/466.ccls. and (silicon or Si) and	USPAT;	2004/10/13 10:37
	•	(spark\$process\$3 or spark\$plasma or (spark	US-PGPUB;	2004/10/13 10.3/
		near9 plasma))	EPO; JPO;	
		nous planta,,	DERWENT;	
			IBM TDB	
-	449	427/204.ccls.	USPAT;	2004/10/18 10:48
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	12	427/204.ccls. and spark\$3	USPAT;	2004/10/18 10:04
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
1_	82	204/178.ccls.	IBM_TDB USPAT;	2004/10/18 10:08
_	82	204/1/0.0015.	US-PGPUB;	2004/10/10 10:08
			EPO; JPO;	
			DERWENT;	
			IBM TDB	·
-	5	204/178.ccls. and silicon	USPAT;	2004/10/18 10:09
	1		US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
1	!		IBM_TDB	
-	317	204/192.23.ccls.	USPĀT;	2004/10/18 10:11
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		1,00,400,00	IBM_TDB	0004/10/10 10 1
-	254	204/192.23.ccls. and silicon	USPAT;	2004/10/18 10:11
			US-PGPUB;	.
			EPO; JPO; DERWENT;	
1			IBM TDB	
L	L	<u></u>	1 100	

		1.001/400 00 1		0004/10/10 10:15
_	4	(204/192.23.ccls. and silicon) and spark\$3	USPAT; US-PGPUB;	2004/10/18 10:15
			EPO; JPO;	,
			DERWENT;	
· .			IBM_TDB	
-	248	204/192.37.ccls.	USPAT;	2004/10/18 10:14
			US-PGPUB;	
			EPO; JPO;	
			DERWENT; IBM TDB	
l _	209	204/192.37.ccls. and silicon	USPAT;	2004/10/18 10:11
	200	201/19210/100201 did 01110011	US-PGPUB;	2001, 10, 10 10, 11
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	4	(204/192.37.ccls. and silicon) and spark\$3	USPAT;	2004/10/18 10:11
			US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM TDB	
-	6	204/907.ccls.	USPAT;	2004/10/18 10:15
		·	US-PGPUB;	
		,	EPO; JPO;	
			DERWENT;	
	434	205/157.ccls.	IBM_TDB	2004/10/18 10:15
-	434	203/137.0018. 	USPAT; US-PGPUB;	2004/10/18 10:13
			EPO; JPO;	
			DERWENT;	, ,
			IBM_TDB	
-	3	205/157.ccls. and spark\$3	USPĀT;	2004/10/18 10:18
			US-PGPUB;	
			EPO; JPO;	
		· .	DERWENT; IBM TDB	
_	33	106/134.2	USPAT;	2004/10/18 10:19
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		106/124 2 and analytic	IBM_TDB	2004/10/10 10:10
-	0	106/134.2 and spark\$3	USPAT; US-PGPUB;	2004/10/18 10:19
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
-	1	106/134.2 and silicon	USPĀT;	2004/10/18 10:19
			US-PGPUB;	
		·	EPO; JPO;	
			DERWENT; IBM TDB	
_	651	427/580.ccls.	USPAT;	2004/10/18 10:48
		1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	US-PGPUB;	
			EPO; JPO;	
1			DERWENT;	
	4	107/500	IBM_TDB	0004/10/10 10 10
-	173	427/580.ccls. and silicon	USPAT;	2004/10/18 10:48
			US-PGPUB; EPO; JPO;	
			DERWENT;	8
			IBM TDB	
-	5	(427/580.ccls. and silicon) and	USPĀT;	2004/10/18 10:57
		(spark\$process\$3 or (spark\$3 near9	US-PGPUB;	'
		(process\$3 or silicon or Si)))	EPO; JPO;	
			DERWENT;	
_	2	electro\$spark near5 deposition and silicon	IBM_TDB USPAT;	2004/10/18 10:58
			US-PGPUB;	2004, 10, 10 10.30
			EPO; JPO;	
			DERWENT;	
L			IBM TDB	

	,			
-	15	electro\$spark and deposition and silicon	USPAT;	2004/10/18 10:59
			US-PGPUB;	
	ł		EPO; JPO;	
			DERWENT;	
	}		IBM_TDB	
-	1	"20010018938"	US-PGPUB	2004/10/19 10:19
-	1	5720917.pn.	USPAT	2004/10/19 10:21
-	1	5756924.pn.	USPAT	2004/10/19 10:23
- ·	1	6613276.pn.	USPAT	2004/10/19 10:23
-	1		USPAT	2004/10/19 10:29
_	0	47724498.pn.	USPAT	2004/10/19 10:29
-	1	4772498.pn.	USPAT	2004/10/19 10:46
_	6300	syringe and (silicon or Si) and plasma	USPAT;	2004/10/19 10:57
			US-PGPUB;	
			EPO; JPO;	
1			DERWENT;	
			IBM TDB	
_	686	(syringe and (silicon or Si) and plasma)	USPAT;	2004/10/19 10:58
		and particles near9 liquid	US-PGPUB;	
		did particiones illustratura	EPO; JPO;	·
			DERWENT;	
			IBM TDB	
_	0	((syringe and (silicon or Si) and plasma)	USPAT;	2004/10/19 10:58
0	"	and particles near9 liquid) and (anode or	US-PGPUB;	2004,10,13 10.30
		cathode) near9 (hypodermic\$needle or	EPO; JPO;	
		needle or syringe)	DERWENT;	
		needle of Syllinge)	IBM TDB	
_	36	syringe near9 metal and (silicon or Si)	USPAT;	2004/10/19 12:16
	30	and plasma	US-PGPUB;	2004/10/13 12:10
		and prasma	EPO; JPO;	
			DERWENT;	
			IBM TDB	1
_	7126	needle and (silicon or Si) and plasma	USPAT;	2004/10/19 10:57
-	/426	I heedle and (Silicon of Si) and plasma	US-PGPUB;	2004/10/19 10:57
			EPO; JPO;	1
			DERWENT;	
			IBM TDB	
·_	686	(needle and (silicon or Si) and plasma)	USPAT;	2004/10/19 10:58
-	686	and particle near9 liquid	US-PGPUB;	2004/10/19 10:38
		and partitite hears riquid	EPO; JPO;	
			DERWENT;	
	5	//mondle and /miliman on Cil and mlasses	IBM_TDB	2004/10/19 10:59
-	5	((needle and (silicon or Si) and plasma)	USPAT;	2004/10/19 10:59
		and particle near9 liquid) and (anode or	US-PGPUB;	
		cathode) near9 (hypodermic\$needle or	EPO; JPO;	
		needle or syringe)	DERWENT;	
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	1	6280799.URPN.	USPAT	2004/10/19 11:03